



PATENT APPLICATION  
Do. No. 1941-76

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Jun LIU; Karel DOMANSKY; Xiohong LI; Glen E. FRYXELL; Suresh BASKARAN; Nathan J. KOHLER; and Suntharampillai THEVUTHASAN

Serial No. 09/837,885

Examiner: Unknown

Filed: April 18, 2001

Group Art Unit: Unknown

For: MESOPOROUS SILICA FILM FROM A SOLUTION CONTAINING  
A SURFACTANT AND METHODS OF MAKING SAME

Date: September 28, 2001

**BOX FEE AMENDMENT**

Assistant Commissioner for Patents  
Washington, D.C. 20231

**PRELIMINARY AMENDMENT**

Please amend the application as follows, prior to examination of the application on its merits.

**IN THE CLAIMS**

Please add new claims as follows:

21. (New) A surfactant-templated mesoporous dielectric film on a substrate prepared from a silica precursor solution by evaporation, wherein the film is characterized by disordered porosity.

22. The dielectric film of claim 20, wherein the silica precursor includes one or more of methyl and ethyl groups.

10/11/2001 ANABI1 00000011 131703 09837885

01 FC:203		27.00 OP
02 FC:202	2.00 CH	40.00 OP